Support Request Form 利用相談フォーム

Please fill in this form and send it to Electron Microscopy Unit office as an email attachment. 依頼内容をご記入いただき、電子顕微鏡ユニット事務局までメール添付にてお送りください。
<u>Email: tem@nims.go.jp</u>

The technical staff member in charge will provide a usage consultation based on the following information.

以下の内容をもとに、担当の技術スタッフが利用相談を行います。

⟨Date 日付: month 目 day 日 vear 年⟩

\Date 🗀 i	· · · · ·	Use	r info	rmation 利用者情報			
	Name 氏名(フリガナ)						
Applicant 申請者	Company (Organization)/Division 会社(組織)名・所属						
	Job Title/Position 職名/肩書						
	Grade For students Period of stay in NIMS for members			NIMS internship progran	n		
	Period of stay in NIMS for visiting re			rchers			
	E-mail address				ı	Phone Number	
	Name 氏名(フリガナ	·)					
Supervisor 責任者	Company (Organizati 会社(組織)名·所属	ompany (Organization)/Division 社(組織)名・所属					
天江日	Job Title/Position #	哉名/肩書					
	E-mail address		-		ı	Phone Number	
	i	For NIMS u	sers c	only NIMS 内部利用者	かっ		
Please fill in an application ID if obtained. 既に課題 ID を取得済みの方はご記入ください。 ID: NM Ex) 24NMXXXX				About Data Provision			
For people from companies and academia 企業・大学等の方へ							
	For peop	ne irom com	panie	es and academia	ᅜᅑ	7 () () () ()	
	FOI PEOP e option regarding the resea た研究成果公開の有無について、	arch outcomes o	otained	through shared use.] Di	sclosure of Research R	esults 成果公開 rch Results 成果非公開
共用設備利用で得 Please answer t	e option regarding the resea	arch outcomes o どちらかを選択し data provision if v	- otained C下さい。 /ou are	through shared use. considering using "ARIM"	□ Di	sclosure of Research R on-Disclosure of Resea	rch Results 成果非公開 n data provision for ARIM. 提供について検討している out data provision. F ARIM を利用する
共用設備利用で得 Please answer t	e option regarding the resea た研究成果公開の有無について、 he following options about o	arch outcomes o どちらかを選択し data provision if v pは、データ提供ご	otained て下さい /ou are ஃカの有	through shared use. considering using "ARIM"	□ Di	sclosure of Research Ron-Disclosure of Resea □ I am interested in ARIM へのデータ: □ I use ARIM withor データ提供無して	rch Results 成果非公開 n data provision for ARIM. 提供について検討している out data provision. F ARIM を利用する

Selection of the usage type and related questions 利用形態の選	選択と質問
Please select A or B for your preferred usage type. 利用形態のご希望について、A もしくは For the selected usage type (A or B), please check the ones that apply to you. 選択した利用	
□ A. Equipment Operation by users 機器利用	
⇒ Operate equipment and acquire data by yourself ユーザー自身が機器を操	作しデータを取得
▶Please select the type of equipment you wish to use and <i>provide the name of the equi</i> ones. (e.g., JEM-2100) ご希望の装置種を選択いただき、指定機器があれば <i>装置名をご記。</i> □ TEM :	
□ SEM :	
□ FIB :	
 ▶ Which of the following would you judge your experience to be? あなたの経験は次のどこ □ Having no experience at all 全く経験がない □ Having enough practical skill 十分経験がある 	れに当てはまると思いますか?
► Please indicate for reference the model(s) you have experience in NIMS by checking b	ooxes or write the name.
参考のため、NIMS 施設で使用経験のある装置にチェックを入れて下さい。リスト以外の場	
Equipment model name	Equipment location
	Equipment location SENGEN site (Advanced Structural Materials)
Equipment model name	Equipment location SENGEN site
Equipment model name □ JEM-ARM300F, □ JEM-2800, □ JSM-7900F, □ SMF-1000, □ Scios2, □ Auriga Laser	Equipment location SENGEN site (Advanced Structural Materials) SENGEN site
Equipment model name ☐ JEM-ARM300F, ☐ JEM-2800, ☐ JSM-7900F, ☐ SMF-1000, ☐ Scios2, ☐ Auriga Laser ☐ JEM-2100F, ☐ JEM-2100, ☐ JEM-ARM200F, ☐ Helios 650, ☐ NB5000, ☐ JIB-4000	Equipment location SENGEN site (Advanced Structural Materials) SENGEN site (Physical Analysis Laboratories)
Equipment model name	Equipment location SENGEN site (Advanced Structural Materials) SENGEN site (Physical Analysis Laboratories) NAMIKI site
Equipment model name □ JEM-ARM300F, □ JEM-2800, □ JSM-7900F, □ SMF-1000, □ Scios2, □ Auriga Laser □ JEM-2100F, □ JEM-2100, □ JEM-ARM200F, □ Helios 650, □ NB5000, □ JIB-4000 □ Talos F200X, □ Ethos NX5000, □ NanoMill Model1040 Equipment other than the above 上記以外の装置: □ □ B. Equipment Operation on behalf of users 技術代行 ⇒ □ Operate equipment and acquire data by EM unit 電子顕微鏡ユニットによる ▶ Please check appropriate boxes as follows. 当てはまるものにチェックを入れて下さい。 □ TEM Sample preparation and TEM observation TEM 試料作製と TEM 観察 □ Only TEM sample preparation TEM 試料作製のみ □ Only TEM observation TEM 観察のみ	Equipment location SENGEN site (Advanced Structural Materials) SENGEN site (Physical Analysis Laboratories) NAMIKI site
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			Sample Information 試料情報			
Sample Name 試料名						
Sample Type, Form, Structure 試料の構成			□ Bulk バルク □ Monolayer 単層膜 □ Multilayer 多層膜 □ Nano-sized particles ナノサイズ粒子 □ Micron-sized particles ミクロンサイズ粒子 □ Others: その他:			
Electrical Characteristics 電気特性			□ Conductor 導体、□ Semi-conductor 半導体、□ Insulator 絶縁体			
Magnetic Property		magnetic (Ferr	Co/Ni) 強磁性(鉄/コバルト/ニッケルなど) ite etc.) フェリ磁性(フェライトセラミックスなど) 生			
Elements contained in the sample 含有元素						
biological components, please answer the questions on the right." 生物由来の材料を含む場合は、 方の設問に回答ください		Does it contain pathogens? 病原を含みますか?		☐ Yes ☐ No		
		Can it be handled in a regular laboratory without a BSL rating and not equipped for GMO experiments? □ Yes □ No 扱えますか?				
		Precautions v	/hen handling sample 試料に関する注意事項			
☐ Toxic 劇物·毒物☐ Heat-resistant ten☐ Intolerance for org☐ Destruction Allow☐ Others to be note	nperature ganic solv ed 破壊可	耐熱温度 [ent such as eth □ Destruc	□ Volatile 揮発性 □ Oxidizable 酸化性 □ Photoreactive 光反 °C] □ Water reactive 水反応性 nanol or acetone 耐薬品性(アセトン・エタノール) ction not Allowed 破壊不可]	反応性		

- Pease fill in the following only if you wish to have a "Technical Surrogate".以下は技術代行をご希望の方のみご記入ください。
- If you do not have enough space, please add pages. Other attachment accepted.
 スペースが足りない場合は、ページを追加してください。別紙添付でも可

Number of Samples 試料数		
Please set priorities for which sample to sta	rt with If there is more than one sample.	
試料が複数ある場合、優先順位を教えて下さい		
Directions of observation 観察方向	□ Cross section 断面 □ Plan view 平面	□ Any direction 方位不問
Sample disposal 試料廃棄について	□ It is OK to dispose of them. 廃棄してよ□ I need the samples returned. 試料の返	
Detailed information about your sample 詳綿		
※ Not necessarily required if sample preparation	is not requested. 試料作製を依頼しない場合は。	必須ではない
Initial form, size, surface roughness, crystal understand using schematic drawings or pl and unusable solvent. 初期形状・サイズ、表面の状態、観察したい	orientation to observe, region of interest as notos. In case of Crash and Dispersion metals は 特定の加工希望位置の全体写真とそのなど懸濁が必要な場合は、使える溶媒と使えない	specifically as possible to easy hod, write the name of usable の部分の拡大写真、平面図、断

Detailed information about analytical techniques you request 依頼したい分析手法
※You don't need this information if you request only sample preparation. 試料加工のみ依頼の場合は不要
TEM: HR-TEM, STEM-EDS, STEM-EELS, EDS Mapping, Line Analysis, Electron Diffraction Pattern etc. HR-TEM、STEM-EDS、STEM-EELS、マッピング、線分析、電子線回折図形等。
SEM: surface observation, cross-sectional observation, EDS measurement, EBSD measurement etc. 表面観察,断面観察,EDS 測定,EBSD 測定等
<u> </u>